Fabrication of Ga₂O₃ polymorphs with ion beams

Gregor Hlawacek^{1*}, Flyura Djurabekova², Andrej Kuznetsov³

¹ Helmholtz-Zentrum Dresden Rossendorf, Dresden, Germany

² University of Helsinki, Helsinki, Finland

³ University of Oslo, Oslo, Norway

* presenting author e-mail: g.hlawacek@hzdr.de

Gallium oxide (Ga₂O₃) is a highly versatile material with applications in power electronics, optoelectronics, sensors, and battery technologies. Importantly, Ga₂O₃ may be formed in several crystalline lattices, called polymorphs, having the same chemical nature, but variable physical properties. In this project, our specific objective is to gain control over the polymorph conversion mechanisms using a recently discovered ion beam based method of disorder-induced ordering [1]. As a result, we aim to establish novel synthesis routes for Ga₂O₃ polymorph films, buried layers, and nanostructures, applying both broad-area and focused ion beams for the polymorph conversion. Perhaps the most spectacular highlight of our work so far, is the discovery of the unprecedentedly high radiation tolerance in the double polymorph Ga₂O₃ structures [2]. Moreover, we show that ion beams may enable formation of the planar multilayered polymorph repetitions [3] and laterally resolved polymorphic nanopatterns, paving the way for enhancing functionalities based on combinations of different polymorphs and their interfaces. Thus, in this paper, we present an overview of our work emphasizing on the understanding and potential applications of our data.

Project GoFIB was selected in the Joint Transnational Cofund Call 2021 of M-ERA.NET 3, which is an EU-funded network under Horizon 2020 grant agreement No 958174. The project is funded by the Research Council of Norway (project No 337627), the tax funds on the basis of the budget passed by the Saxonian state parliament in Germany, and the Academy of Finland (project No 352518).

References

[1] A.Azarov, C.Bazioti, V.Venkatachalapathy, P.Vajeeston, E.Monakhov, and A.Kuznetsov, Disorder-Induced Ordering in Gallium Oxide Polymorphs. Phys Rev Lett, 128, 15704(2022)

[2] A. Azarov, J. Garcia Fernandez, J. Zhao, F.Djurabekova, H.He, R.He, Ø.Prytz, L.Vines, U.Bektas, P.Chekhonin, N.Klingner, G.Hlawacek, and A.Kuznetsov, "Universal radiation tolerant semiconductor," Nature Communications, 14, 4855 (2023)

[3] A.Azarov, C.Radu, A.Galeckas, I.F.Mercioniu, A.Cernescu, V.Venkatachalapathy, E.Monakhov, F.Djurabekova, C.Ghica, J.Zhao, and A.Kuznetsov, Self-assembling of multilayered polymorphs with ion beams, Nano Letters 25, 1637(2025)